

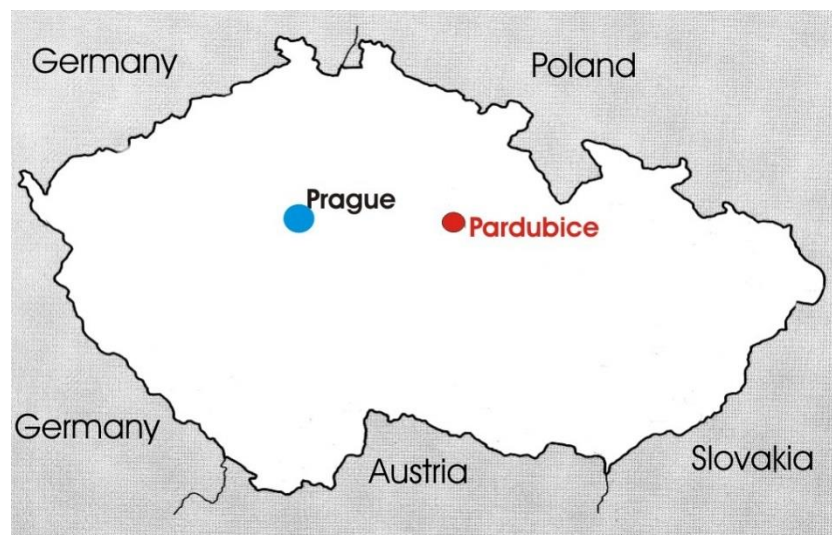
ALTERNATIVE ANTIMICROBIAL SYSTEMS BASED ON PHOTOACTIVE MATERIALS

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Company introduction



- Private research company founded in 2009
- R&D of organic compounds for application in industry and science
- Core business – electronics, photosensitizers, UV protection
- Up scaling and transfer of technology
- Small batch production of new compounds



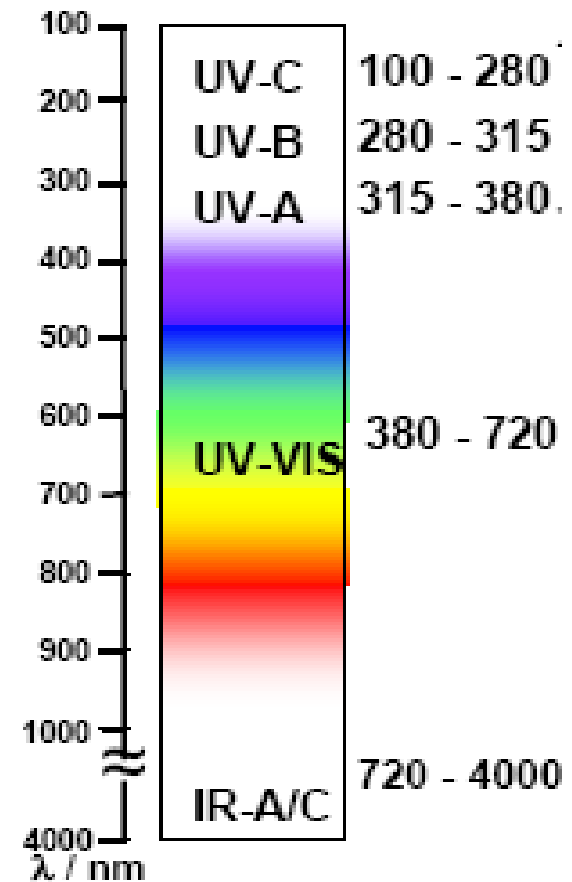
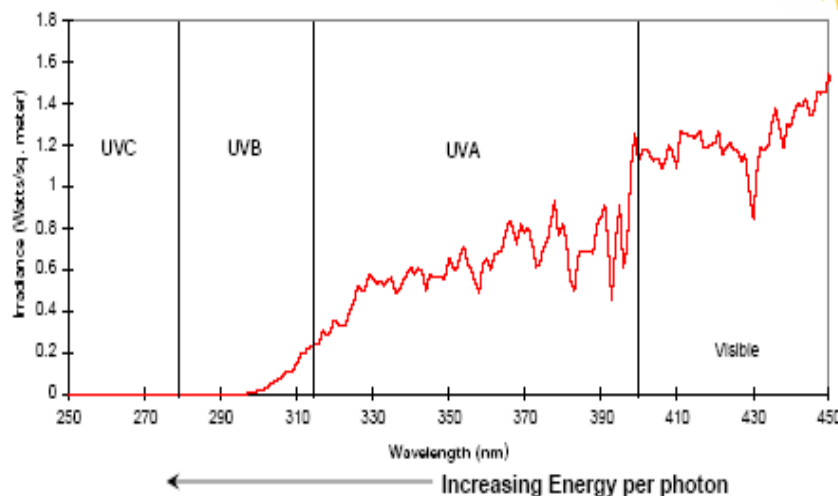
Photoactive materials



- Inorganic metal oxides, activated by UV radiation
- Derivatives of organic colorants, activated by VIS radiation

Spectral Energy Distribution of Natural Sunlight

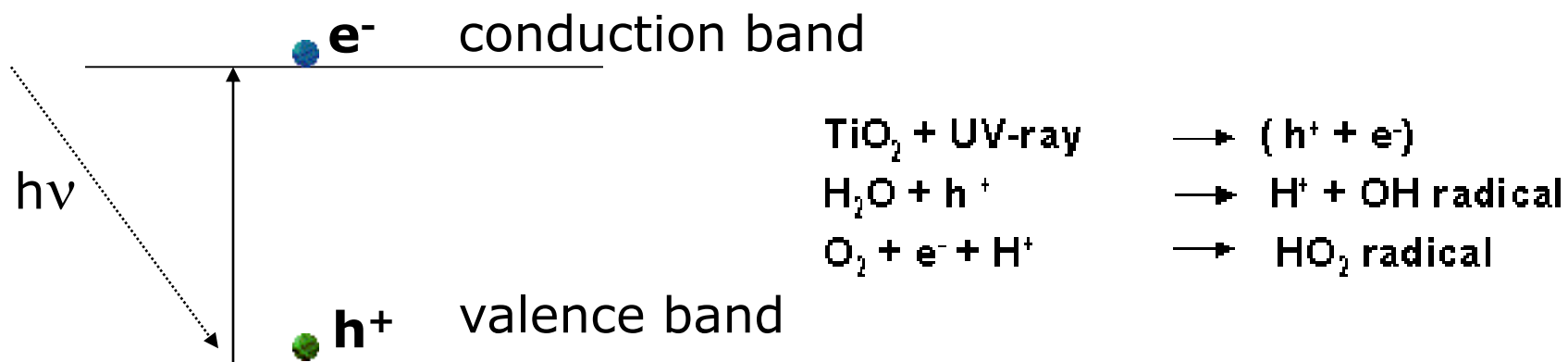
Miami, Florida (June 17, 1983)



TiO₂ – efficient inorganic photosensitizer



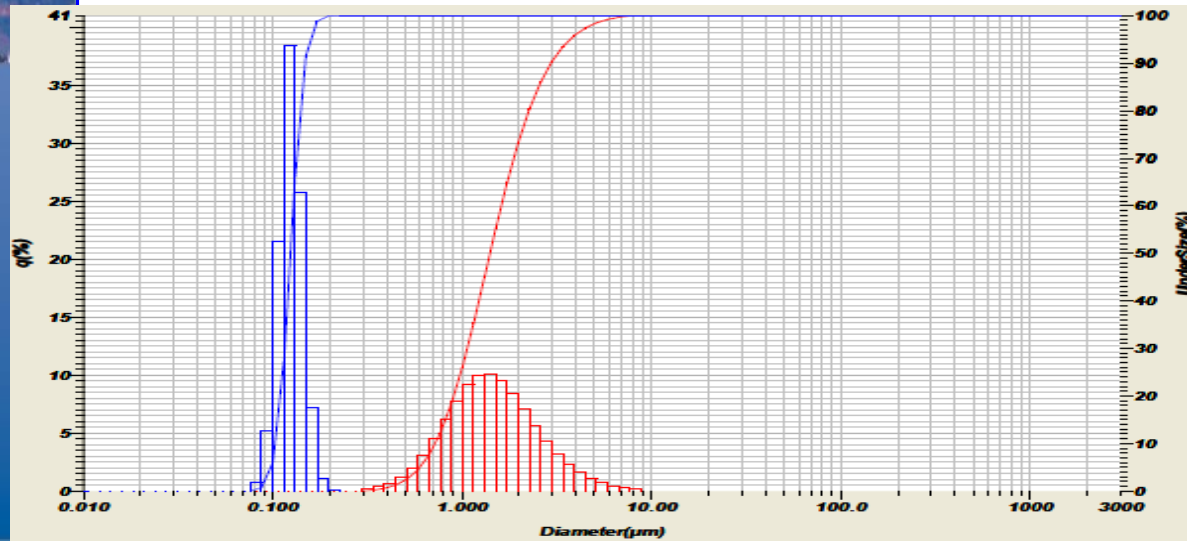
- TiO₂ is highly efficient inorganic photoactive semiconductive material
- Efficiency of photoactivity depends on its surface weight
- Nanoform brings high photoactivity



Antimicrobial process has some limitations



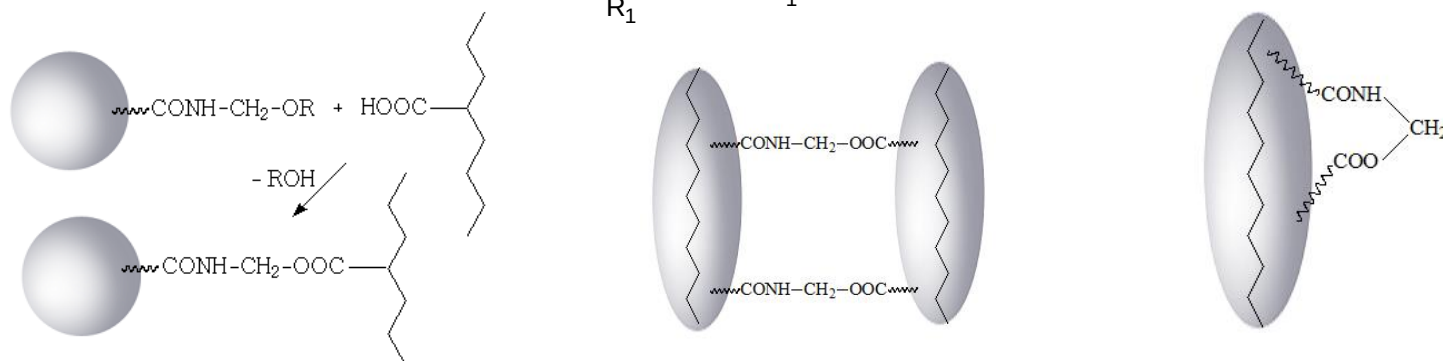
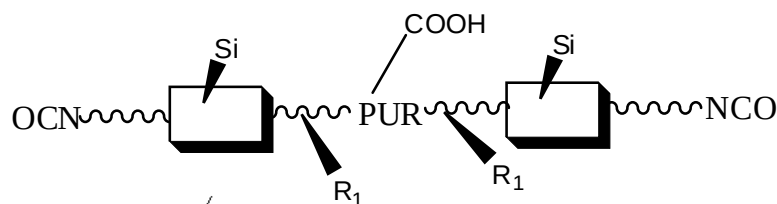
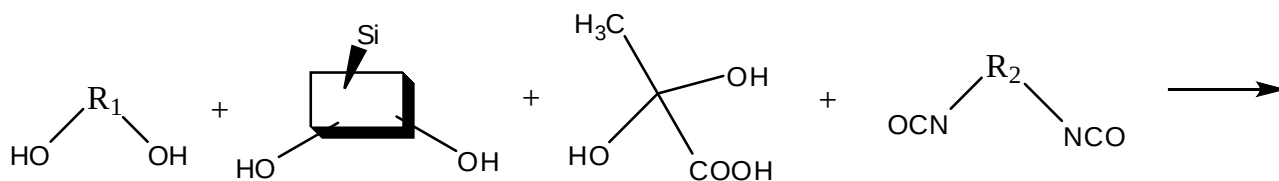
- TiO_2 needs for activation relevant source of UV radiation – the most effective Sun outdoor radiation
- Nanoparticles of TiO_2 make agglomerates – it is necessary to prepare dispersions by pearl milling
- The production of free radicals is highly destructive for all organic materials including carrier polymers
- The photoactive process is too slow – is not suitable for fast disinfection



Self-cleaning fabrics



- Incorporation of hybrid silicon-acryl-urethane thermofixative polymeric system as carrier of TiO_2 on textile

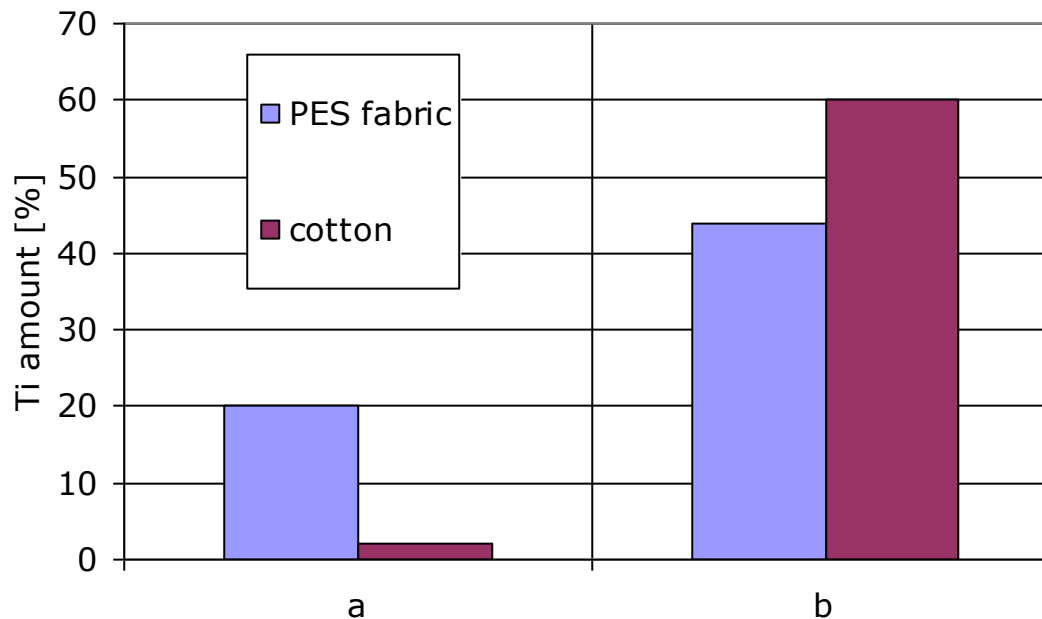


CZ 304812

Self-cleaning fabrics



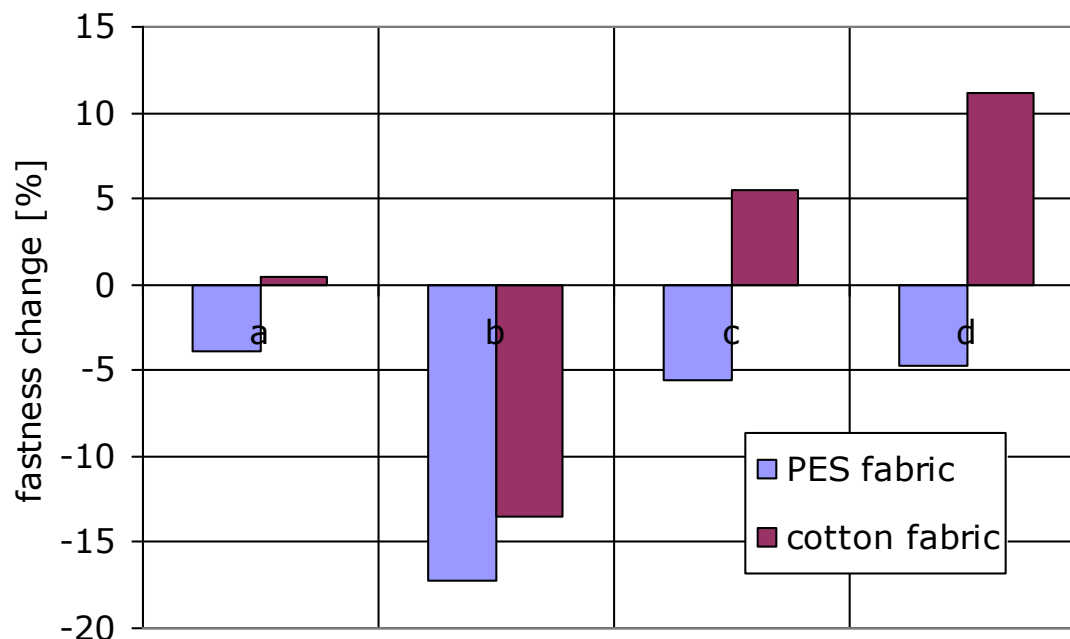
Wash-fastness of TiO_2 in modified fabrics



a) fabric modified by TiO_2 by standard method

b) fabric modified by mixture of TiO_2 and SIPURINO

Mechanical stability of modified fabrics – tensile strength

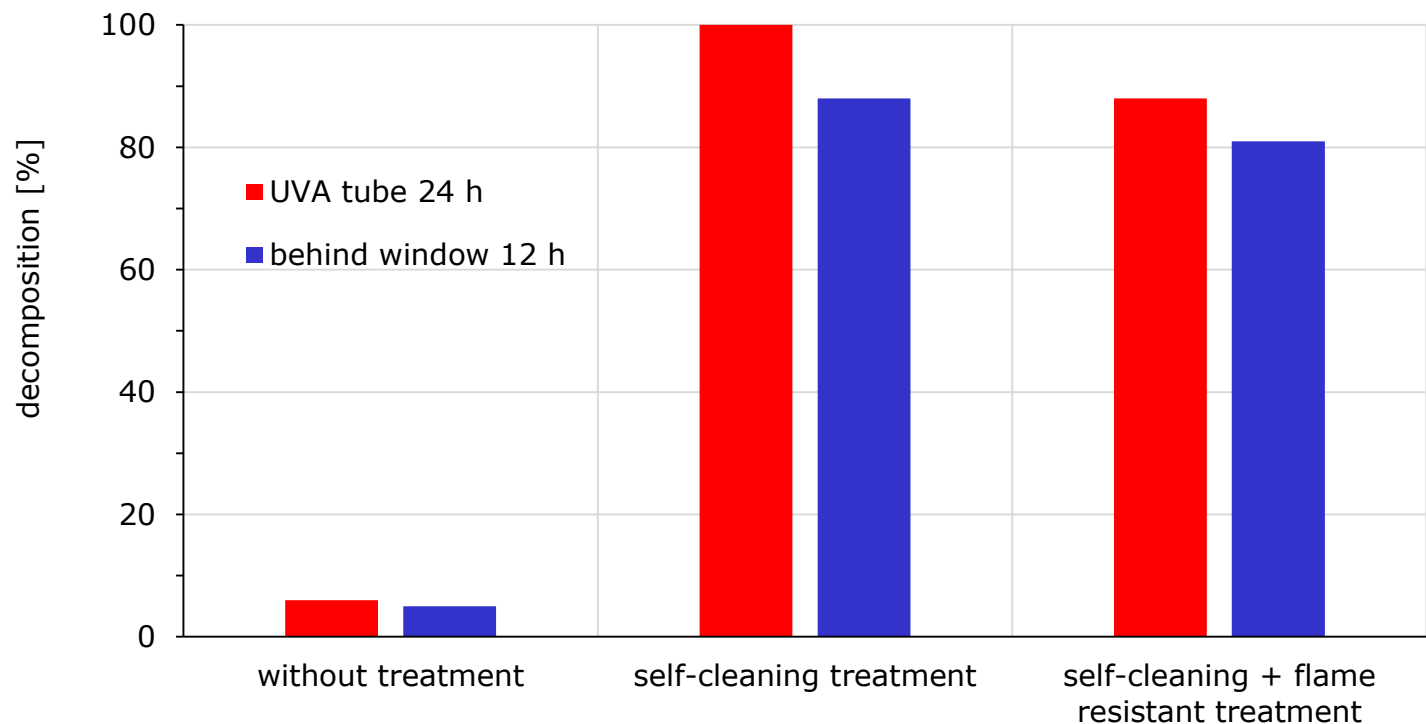


- a) fabric without modification; b) fabric modified by TiO_2 alone;
c) fabric modified by TiO_2 and SIPURINO;
d) fabric modified by SIPURINO

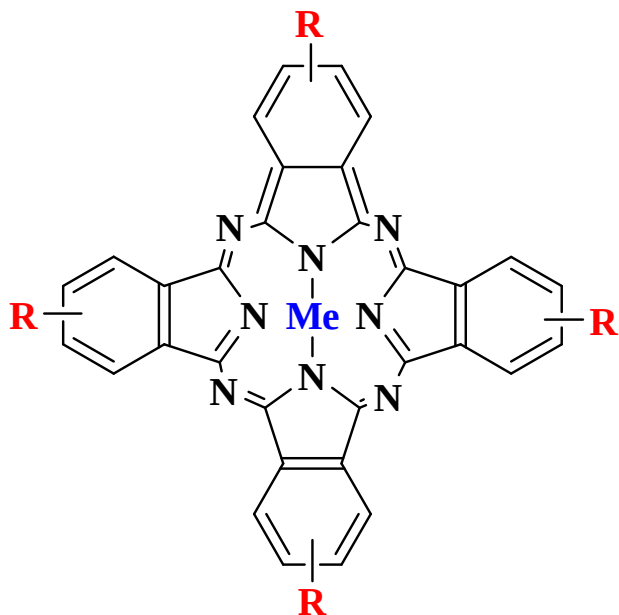
Self-cleaning fabrics



Decomposition efficiency against formaldehyde



Phthalocyanine (Pc) as organic photosensitizer



Me – Zn, Al

R – H

- solubilizing group

- polymerizing group

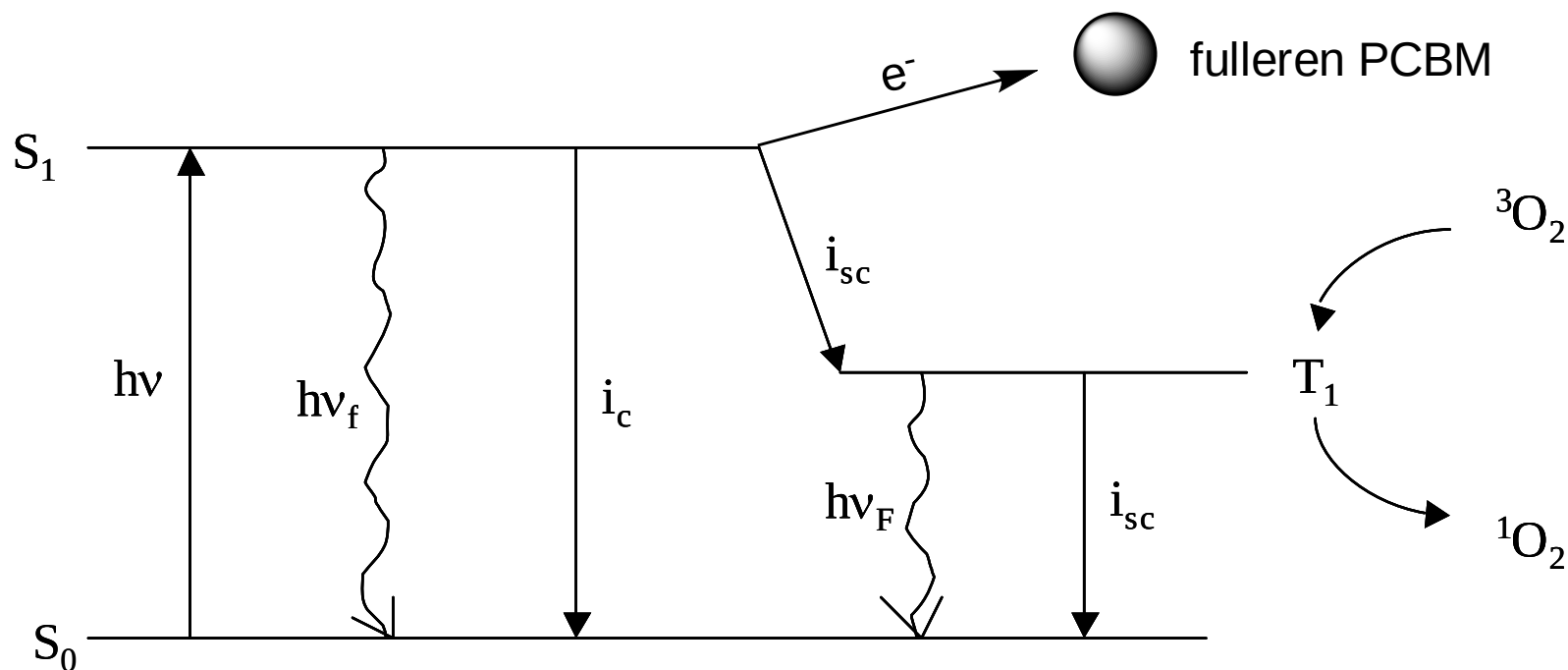
Application in the form:

- Dispersion
- Solution
- Reactive bound into polymer structure

Phthalocyanine (Pc) as organic photosensitizer



Jablonski diagram



Application of Pc in the solution



Cutting fluids for Engineering

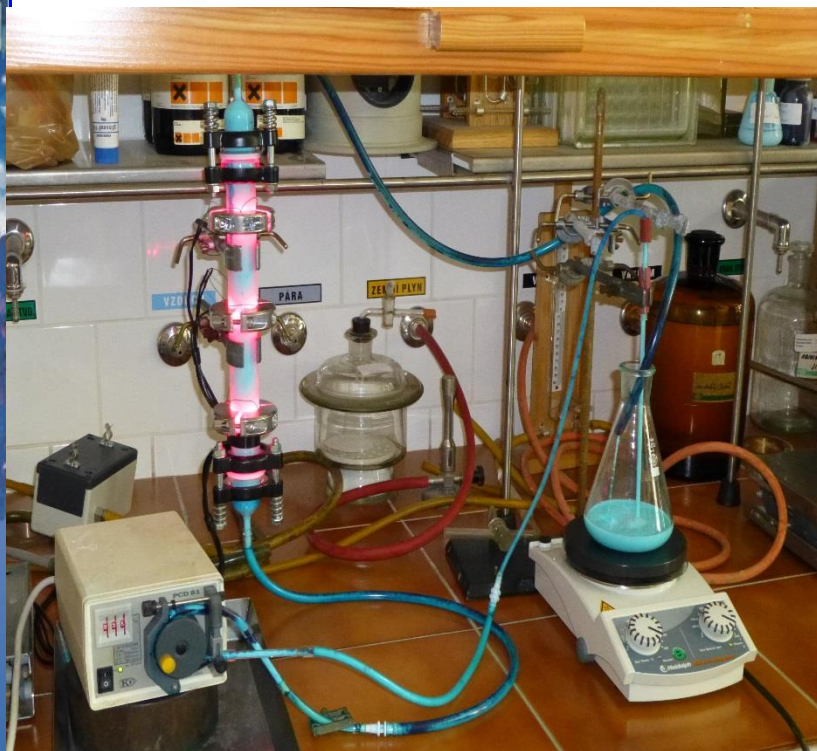
- Conventional biocides are not stable
- Conventional biocides makes serious dermatitis
- Mixture of oil and water is suitable environment for yeasts, bacteria and moulds



Application of Pc in the solution



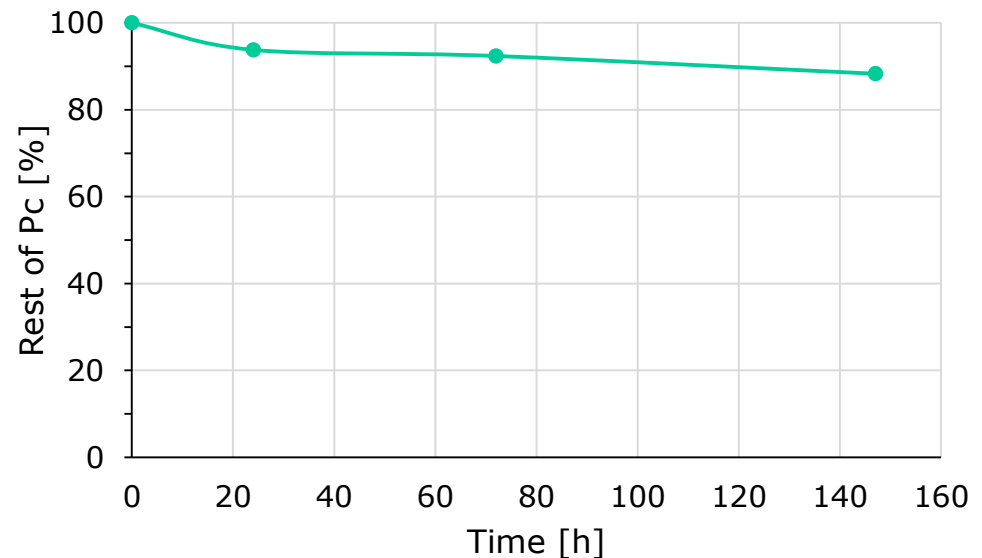
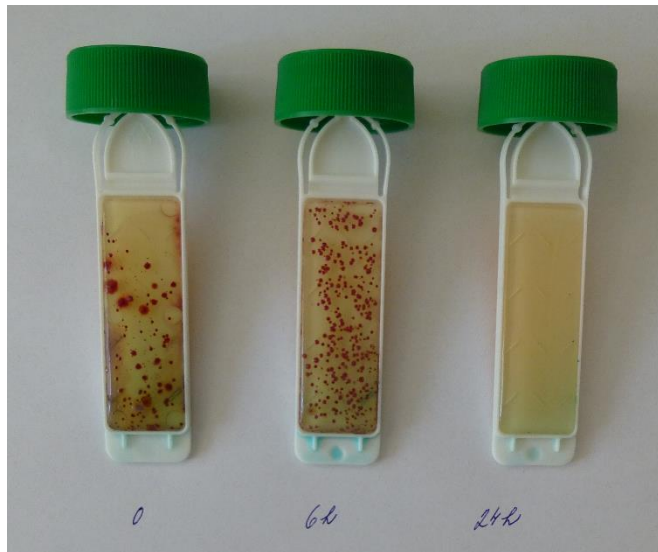
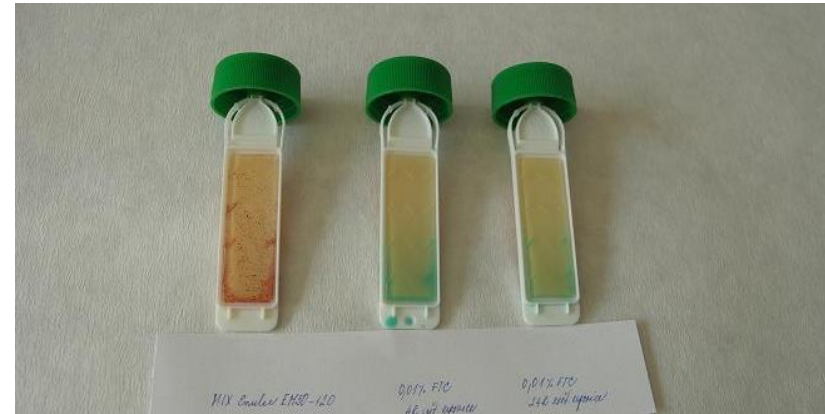
Laboratory and pilot plant tests



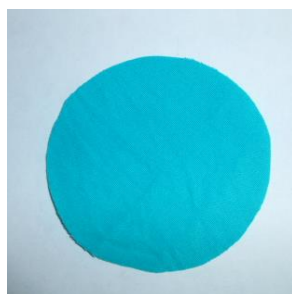
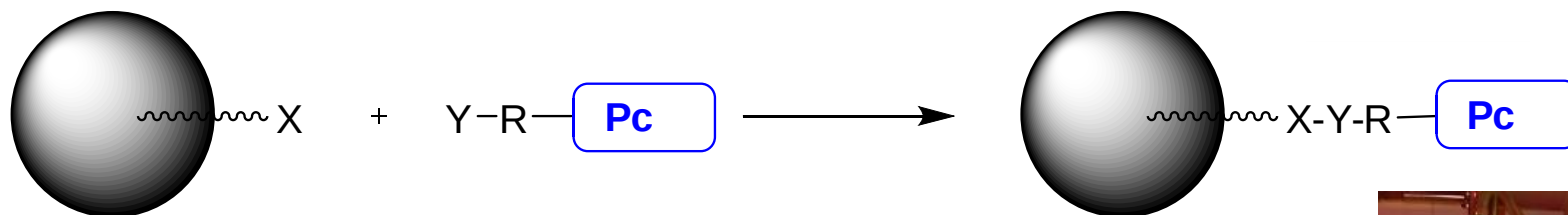
Application of Pc in the solution



Cult dip test for bacteria existence evaluation



Application of Pc bonded on textile fabrics



washing



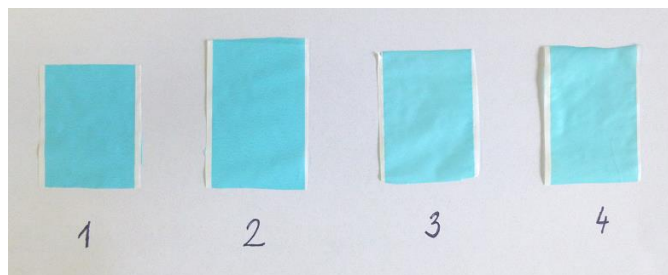
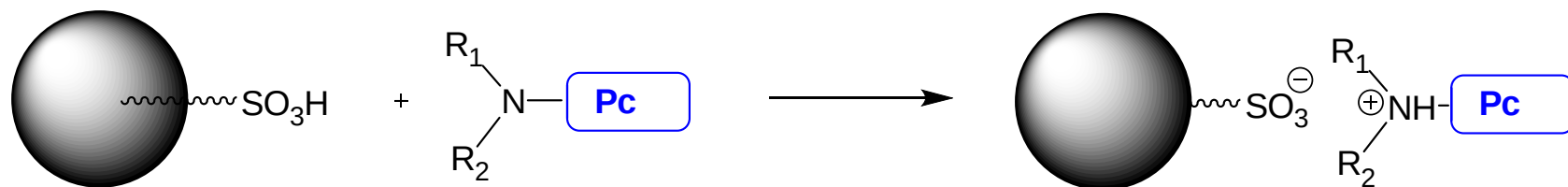
<i>Escherichia coli</i> - log CFU/ml					
Central metal of Pc	starting bacterial suspension	cotton - blank	dyed cotton	5x washed	10x washed
Al	4,0	4,0	1,0	1,7	2,9
Zn	4,0	4,0	0,2	1,3	2,0

Application of Pc applied on foil



Application of flexography printing inks

- Pc bound on polymeric matrix by ionic bond
- Application of inks on vapor permeable foil
- Antimicrobial protection of foil
- Application mainly for health care



Application of Pc applied on foil



	Escherichia coli CNCTC 6244		Staphylococcus aureus CCM4516	
	0 hod	24 hod	0 hod	24 hod
Blank sample - irradiated	$7,4 \cdot 10^4$	$2,5 \cdot 10^2$	$6,6 \cdot 10^4$	$1,2 \cdot 10^2$
Blank sample without irradiation	$7,4 \cdot 10^4$	$1,1 \cdot 10^7$	$6,6 \cdot 10^4$	$2,7 \cdot 10^6$
Sample with Pc - irradiated	$7,4 \cdot 10^4$	< 10	$6,6 \cdot 10^4$	< 10
Sample with Pc without irradiation	$7,4 \cdot 10^4$	$9,3 \cdot 10^6$	$6,6 \cdot 10^4$	$2,6 \cdot 10^6$



Application of Pc applied on foil



Roll to Roll application system

- From laboratory into plant
- Fatra Sontec foil product



Conclusion



- Antimicrobial behaviour of photoactive materials was demonstrated
- System of application of photoactive TiO_2 for self-cleaning and antimicrobial application suggested
- System was tested with self-cleaning fabrics
- Photoactive phthalocyanine as efficient antimicrobial agents were developed
- Application in soluble form for cutting fluids antimicrobial protection
- Application after covalent bonding on cotton fabrics with antimicrobial behaviour
- Application as printing inks for vapour permeable foils for health care

ACKNOWLEDGEMENT



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Thank you for your attention!

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